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Signature

Appl No.

: 10/625,316

Confirmation No. 7750

Applicant

: Sriram Venkatasanthanam, et al.

Filed

: July 23, 2003

Title

: METHOD FOR FORMING INHERENTLY

INK-RECEPTIVE FILM SUBSTRATES

TC/A.U.

: 1732

Examiner

: Mark Eashoo

Docket No.

: 50770/A23

Customer No.

: 23363

RESPONSE

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Post Office Box 7068 Pasadena, CA 91109-7068 November 10, 2006

Commissioner:

This is in response to the Office action dated July 10, 2006. Claims 1-5 are pending in the application. Claims 1-4 stand rejected under 35 U.S.C. § 103(a) as being unpatentable over Freedman (US 4,713,273) in view of Yamamoto et al. (US 3,551,538). It appears that claim 5 is also rejected based on the same combination. For the reasons that follow, Applicants respectfully traverse the rejection and request reconsideration.

The Examiner states that "Freedman teaches the basic claimed process of forming an ink receptive substrate comprising: forming a melt processable base layer from a water insoluble thermoplastic polymer (9:65-10:45) and Fig. 6); and coextruding a bas[e] layer and skin or ink receptive layer (9:20-11:10)." The Examiner acknowledges that Freedman does not teach an ink receptive layer formed from a polyolefin and polyethylene oxide.